

Supplementary Material to the article “Perfect absorption by metal-contacted two-dimensional systems with ultra-proximate reflectors”

I. VARIATIONS IN OPTIMAL DISTANCE TO THE REFLECTOR FOR UNIFORM 2DES WITH COMPLEX CONDUCTIVITY

Deviations of optimal d providing the maximization of absorbance from $\lambda_0/4n_{\text{sub}}$ can be observed already at a level of toy model of metal-backed *uniform* 2DES with complex conductivity $\sigma = \sigma' + i\sigma''$ [1]. The Maxwells' equations for the normally incident wave on the layered structure "2DES – substrate – reflector" are solved fully analytically, as the fields throughout all space are uniform (e.g., with transfer matrix technique). The local field in the 2DES plane reads as

$$E = 2E_0 \frac{1 - e^{i\Delta\Phi_g}}{e^{i\Delta\Phi_g}(n - 2\eta - 1) + n + 1 + 2\eta}, \quad (\text{S1})$$

where $\Delta\Phi_g = 2\pi n_{\text{sub}}d/\lambda_0$ is the geometric phase shift in the substrate. The absorbance is found from (S1) simply as

$$\alpha = 2\eta'|E/E_0|^2. \quad (\text{S2})$$

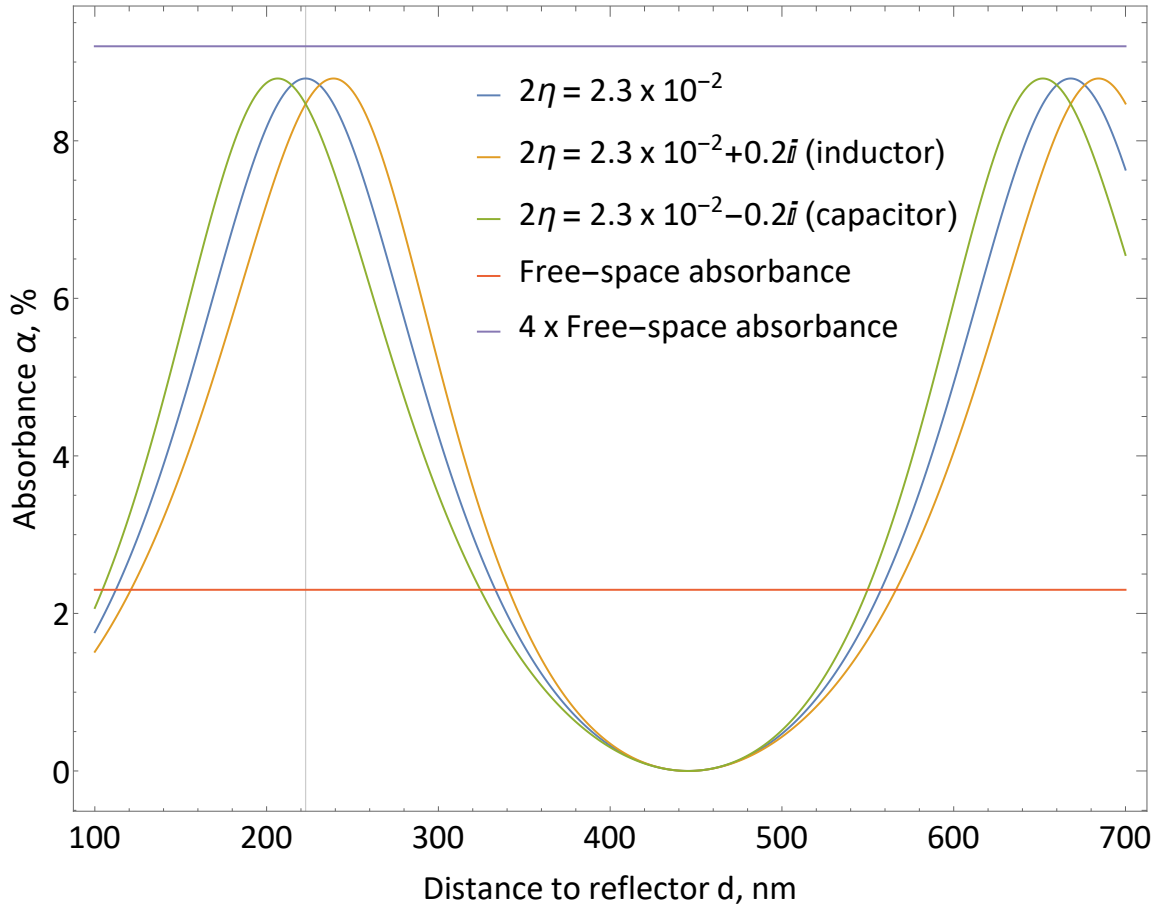


FIG. S1. Absorbance of uniform metal-backed 2DES with real (blue) and artificially added imaginary (orange and green) conductivity vs distance to reflector d . The amendment of capacitive (negative imaginary) part of the conductivity shifts the optimal value of d below $\lambda_0/(4n_{\text{sub}})$ (marked by vertical gray line). Red and violet lines mark the levels of free-space absorbance 2.3 % and its fourfold multiple 9.2 %. The excitation wavelength is $\lambda_0 = 1550$ nm, the substrate refractive index $n_{\text{sub}} = 1.44$

To illustrate the shifts of optimal d with amendment of reactive component of 2DES conductivity, we plot the distance-dependent absorbance computed with (S1, S2) for three representative conductivities $2\eta = 2.3 \times 10^{-2} +$

$\{0, \pm 0.2\}i$, Fig. S1. These correspond to the interband real conductivity of graphene plus some artificial reactive amendment. The excitation wavelength is set to $\lambda_0 = 1550$ nm, the substrate refractive index $n_{\text{sub}} = 1.44$.

The optimal absorbance for real conductivity $2\eta = 2.3 \times 10^{-2}$ occurs precisely at $d = \lambda_0/(4n_{\text{sub}})$, marked by vertical gray line. With amendment of $\text{Im}\eta$, the optimal d shifts from $\lambda_0/(4n_{\text{sub}})$. The shift is positive of $\text{Im}\eta > 0$ (inductive 2DES) and negative for $\text{Im}\eta < 0$ (capacitive 2DES). The demonstrated reduction in optimal d for uniform 2DES with capacitive conductivity provides a simple interpretation why the composite metal-2DES structures (comprising a series of slot capacitors) can be matched at $d < \lambda_0/(4n_{\text{sub}})$.

II. DERIVATION OF OPTIMAL DISTANCE TO THE REFLECTOR FOR METAL-2DES METASURFACE

The optimal distance to the reflector (18) and appearance of the critical value $k_0 L = \pi/n_{\text{sub}}$ can be understood already within the lumped model approximation.

In the presence of a back reflector, perfect absorption requires the cancellation of the reactive part of the effective admittance:

$$\text{Im } G_{\text{eff}} = \text{Im}(\sigma + G_{\text{rad}}) - \omega \text{Re } C_{\text{eff}}. \quad (\text{S3})$$

We now consider $f \ll 1$, $k_0 d \ll 1$ and $\eta'' \ll 1$. The radiative admittance contains a singular contribution

$$Z_0 \text{Im } G_{\text{rad}} = f n_{\text{sub}} \cot(n_{\text{sub}} k_0 d) \simeq \frac{f}{k_0 d}. \quad (\text{S4})$$

A singular contribution of the same order is also contained in C_{eff} . Keeping only the part enhanced as $1/d$, in the limit $f \ll 1$ we obtain

$$C_{\text{eff}} \approx 2f\varepsilon_0 \left[\frac{L}{2\pi}(1 + \varepsilon) \left(\frac{3}{2} - \ln(2\pi f) \right) + \sum_{n=1}^{+\infty} \frac{\varepsilon}{\kappa_{\varepsilon}^2(q_n)d} \right]. \quad (\text{S5})$$

The sum in the second term in the equation S5 has simple form

$$\sum_{n=1}^{+\infty} \frac{\varepsilon}{\kappa_{\varepsilon}^2(q_n)d} = \frac{1}{2k_0^2 d} \left(1 - \frac{L}{\lambda_0} n_{\text{sub}} \pi \cot \left[\frac{L}{\lambda_0} n_{\text{sub}} \pi \right] \right), \quad (\text{S6})$$

which leads to a reduction of the radiation part in the expression for effective admittance

$$Z_0 \text{Im } G_{\text{eff}} \simeq \frac{f n_{\text{sub}} L}{2d} \cot \left(\frac{\pi n_{\text{sub}} L}{\lambda_0} \right) - 2f \frac{L}{\lambda_0} (1 + \varepsilon) S_f, \quad (\text{S7})$$

where $S_f = 3/2 - \ln(2\pi f)$. Solving $\text{Im } G_{\text{eff}} = 0$ with respect to the reflector distance gives Eq. (18) of the main text.

[1] V. M. Muravev, I. V. Andreev, N. D. Semenov, P. A. Gusikhin, and I. V. Kukushkin, Absorption of electromagnetic waves in a screened two-dimensional electron system, Phys. Rev. B **110**, 205416 (2024).